

	Type	L #	Hits	Search Text	DBs	Time Stamp	Com m e n t s	Er r o r s
1	IS&R	L1	3	((("0607808") or ("5505416"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 14:42		0
2	IS&R	L2	4	((("6078088") or ("5055416"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:12		0
3	IS&R	L3	0	("etch\$3same((HClorhydrochloric)with(HF orhydrofluoric))with("lowk"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:13		0
4	IS&R	L4	0	("etch\$3same(((HClorhydrochloric)with(HF orhydrofluoric))with("lowk"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:14		0
5	BRS	L5	0	etch\$3 same (((HCl or hydrochloric) with (HF or hydrofluoric)) with ("lowk"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:16		0
6	BRS	L6	1631	etch\$3 same ((HCl or hydrochloric) with (HF or hydrofluoric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:16		0
7	BRS	L7	1194	etch\$3 with ((HCl or hydrochloric) with (HF or hydrofluoric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:16		0
8	BRS	L8	28	7 with ((low k) or (low dielectric))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:25		0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Com ment s	Er or D ef in iti on	Er ors
9	BRS	L9	43	7 and (("low k") or ("low dielectric"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 15:27			0
10	BRS	L10	1342	etch\$3 same ("low dielectric constant" or "polyimides" or "fluorinated polyimides" or "polysilsequioxane" or "benzocyclobutene" or "BCB" or "parlene" or "amorphous polytetrafluoroethylene" or "low K" or "Flare" or "perfluorobiphenyl" or "doped silicon glass" or "FSG" or "tetraethylorthosilicate" or "TEOS" or "phosphosilicate glass" or "PSG" or "borophosphosilicate glass" or "BPSG" or "spin-on glass" or "amorphous carbon" or "fluorinated amorphous carbon" or "parylene" or "boron nitride" or "BN" or "teflon" or "polynaphthalene-N" or "polynaphthalene-F" or "polyarylene" or "fluorinated polyamide" or "fluorocyclobutene" or "perfluorocyclobutene" or "benzocyclobutene" or "methylsilsequioxane" or "hydrosilsequioxane" or "fluoropolymers" or "porous dielectrics" or "polyamide nanofoam" or "silica aerogel" or "aerogel" or "polymide" or "silicon carbide" or "SiC" or "BLOK") same ((HCl or hydrochloric) and (USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:04			0
11	BRS	L11	344	10 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 16:48			0
12	BRS	L12	849	10 and @pd<=20010829	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:08			0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Com m e n t s	Er r o r D e f i n i t i o n	Er r o r s
13	BRS	L13	188	12 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:12			0
14	BRS	L14	990	(etch\$3 WITH ("low dielectric constant" or "FLOROSILICATE GLASS" OR "ORGANO SILICON GLASS" OR "polyimides" or "fluorinated polyimides" or "polysilsequioxane" or "benzocyclobutene" or "BCB" or "parlene" or "amorphous polytetrafluoroethylene" or "low K" or "Flare" or "perfluorobiphenyl" or "doped silicon glass" or "FSG" or "tetraethylorthosilicate" or "TEOS" or "phosphosilicate glass" or "PSG" or "borophosphosilicate glass" or "BPSG" or "spin-on glass" or "amorphous carbon" or "fluorinated amorphous carbon" or "parylene" or "boron nitride" or "BN" or "teflon" or "polynapthalene-N" or "polynapthalene-F" or "polyarylene" or "fluorinated polyamide" or "fluorocyclobutene" or "perfluorocyclobutene" or "benzocyclobutene" or "methylsilsequioxane" or "hydrosilsequioxane" or "fluoropolymers" or "porous dielectrics" or "polyamide nanofoam" or "silica aerogel" or "aerogel" or "polymide" or "silicon carbide" or "SiC" or "BLOK" or "BLACK DIAMOND" OR "CORAL" OR "SILK")) same ((HCl or hydro	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:08			0
15	BRS	L15	642	14 and @pd<=20010829	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:44			0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Com men ts	Er ro r D ef in iti on	Er ro rs
16	BRS	L16	11	15 and 438/745	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:09			0
17	BRS	L17	147	15 and 438/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:12			0
18	BRS	L18	495	15 NOT 17	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/09 17:44			0

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	2	"20030049938"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/18 13:36			0
2	BRS	L2	9	LAI-JANE-BAI.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/18 13:42			0
3	BRS	L3	5	CHOU-PEI-FEN.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/03/18 13:42			0